



IFW

**PATENT APPLICATION**

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q77065

Makoto MOMOTA

Appln. No.: 10/642,576

Group Art Unit: 1752

Confirmation No.: 2952

Examiner: Yvette C. Thornton

Filed: August 19, 2003

For: POSITIVE PHOTORESIST COMPOSITION

**RESPONSE UNDER 37 C.F.R. § 1.111**

**MAIL STOP AMENDMENT**

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Sir:

In response to the Office Action dated September 21, 2004, please consider the remarks as submitted herewith on the accompanying pages.